

**AMENDMENTS TO THE SPECIFICATION:**

*Please amend the paragraph beginning at page 45, line 13, as follows:*

Next, a charge conveying layer was formed as the outer layer of the charge generating layer. As the coating solution for the charge conveying layer, a solution prepared by adding one part of hydrazone-based charge conveying material (ABPH manufactured by NIPPON KAYAKU CO., LTD), one part by weight of polycarbonate resin (~~Panlite~~ PANLITE L-1250 manufactured by TEIJIN CHEMICALS LTD.) and 0.00013 parts by weight of a silicone-based leveling agent (KF-96 manufactured by Shin-Etsu Chemical Co., Ltd.) to 8 parts by weight of dichloroethane and heating the mixture at 45°C to dissolve and then cooling naturally after the mixture was dissolved was used. This coating solution was applied onto the outer layer of the charge generating layer with the coating apparatus 21 while the thickness of the layer was adjusted, and thus a charge conveying layer having a thickness of about 22  $\mu\text{m}$  was formed. The wavelength of the light used for measurement of the thickness of the layer was 650 to 750 nm, and the reflection spectrum of the combined coated film of the charge generating layer and the charge conveying layer was measured, and the thickness of the combined layer of the charge generating layer and the charge conveying layer was obtained based on Equation (4). Then, the thickness of the charge generating layer was subtracted therefrom to obtain the thickness of the charge conveying layer. In this manner, photoreceptors of Examples 1 to 11 provided with the conductive substrate whose the indices of the surface roughness were in the range of the invention were produced.